# **RSC** Advances



# PAPER

Check for updates

Cite this: RSC Adv., 2021, 11, 3096

Received 28th November 2020 Accepted 6th January 2021

DOI: 10.1039/d0ra10057a

rsc.li/rsc-advances

### Introduction

In the recent past, a surge has been observed in the development of flexible and stretchable electronic devices in various applications including solar cells, touch screen displays, lightemitting diodes, flexible batteries, sensors, and spintronic devices.<sup>1-5</sup> The essential components of such devices are electrodes, which should be thin, lightweight, and highly transparent so that they can be stretched and flexed without compromising their electrical and optical assets. In recent years, indium tin oxide (ITO) has been most frequently used as transparent conducting electrodes (TCEs) in solar-cell application, because it exhibits low sheet resistance and high transparency in visible-light spectrum.<sup>6</sup> Although, it is quite unsuitable for flexible electronics due to their low flexibility, high cost, limited source of indium and inconsistency in the transparency near the ultraviolet region. Among the available

# Investigation of electronic properties of chemical vapor deposition grown single layer graphene *via* doping of thin transparent conductive films<sup>†</sup>

Anand Kumar Singh, <sup>[]</sup><sup>a</sup> Vivek Chaudhary, <sup>[]</sup><sup>b</sup> Arun Kumar Singh <sup>[]</sup><sup>\*c</sup> and S. R. P. Sinha<sup>a</sup>

It is a crucial challenge to obtain the desired electronic properties of two-dimensional materials for various ubiquitous applications and improvements in the existing technology. In this article, we have demonstrated the modulation in electronic features of the chemical vapor deposition (CVD) grown single-layer graphene (SLG) *via* wet doping of poly (3,4-ethylenedioxythiophene) polystyrene sulfonate (PEDOT:PSS). The PEDOT:PSS is well known as conducting polymer and used as transparent conducting electrode in flexible organic electronic devices. The effect of doping on SLG samples were examined by Raman spectroscopy, electrical transport measurement, atomic force microscopy (AFM), and Kelvin probe force microscopy (KPFM). The Raman peaks position of doped samples provided sought evidence of p-type doping of SLG after the deposition of PEDOT:PSS films. The electrical measurement confirmed the p-type doping of SLG and also revealed enhanced carrier density and mobility of SLG after the deposition of PEDOT:PSS films. The electrical measurement confirmed the p-type doping of SLG and also revealed the homogeneous loading of PEDOT:PSS particles over the SLGs. Further, KPFM technique was used to estimate the work function modulation of SLG after PEDOT:PSS film deposition. Our investigation will be useful for understanding the device physics as well as improvement of photovoltaic devices based on PEDOT:PSS coated graphene.

alternatives, graphene has attracted significant interest as TCEs for various optoelectronic devices due to its high transparency and flexibility.<sup>1,7</sup> Graphene is a network of sp<sup>2</sup> hybridization of carbon atoms arranged into a hexagonal structure and is semimetal in nature. Recently, graphene has received considerable interest due to its remarkable properties, including atomically thin, high mechanical strength, thermally stable, and highly transparent two-dimensional sheets as well as high carrier mobility along the sheets.<sup>8,9</sup> Single-layer graphene (SLG) shows high optical transparency ( $\sim$ 98%), electrical conductivity and flexibility, which makes SLG is highly suitable for the TCEs.<sup>10</sup> Among the various synthesis approaches, chemical vapor deposition (CVD) technique is the most effective synthesis approach for large-scale production of graphene due to its various advantages such as high-quality, large-area, low cost, and easily transfer on the desired substrate.11,12

The tuning of charge carrier and doping type of graphene is a potential step for the realization of multifunctional use in current electronic/optoelectronic devices. In addition, shift of the Fermi level ( $E_{\rm F}$ ) position of graphene directly depends on charge carrier doping, and moves upwards or downwards with relative to Dirac point. As reported previously, the electrical properties of pristine graphene can be modulated by various techniques.<sup>13-16</sup> In this context, chemical doping easily modulates the doping type, carrier concentration and work function of graphene.<sup>17</sup> According to previous studies, two types of



Department of Electronics and Communication Engineering, Institute of Engineering and Technology, Lucknow 226021, India

<sup>&</sup>lt;sup>b</sup>Department of Physics, Motilal Nehru National Institute of Technology Allahabad, Prayagraj, 211004, India

<sup>&</sup>lt;sup>c</sup>Department of Pure and Applied Physics, Guru Ghasidas Vishwavidyalaya, Bilaspur 495009, CG, India. E-mail: arunsingh.itbhu@gmail.com

<sup>†</sup> Electronic supplementary information (ESI) available. See DOI: 10.1039/d0ra10057a

chemical dopants such as small molecules and transition metal oxides are widely used for doping in graphene.<sup>18,19</sup> The charge transfer doping of graphene via small-molecule acids (e.g., HNO<sub>3</sub>, SOCl<sub>2</sub>, H<sub>2</sub>SO<sub>4</sub>) and metal chlorides (*e.g.*, AuCl<sub>3</sub>, FeCl<sub>3</sub>) has been extensively investigated to improve the electrical properties of graphene.15,18 However, the small molecular doping of graphene exhibits severe concerns about stability, which has been considered as a barrier for graphene-based TCEs. On the other hand, in the metal chloride doped graphene, metal particles decreases the optical transmittance and due to large particle size leakage current also increases in thinfilm devices.<sup>20</sup> More recently, doping of graphene via conducting polymers have attracted much attention due to several advantages, including cost-effective, highly stable, simple, and also maintained optical transparency and flexibility.<sup>21,22</sup> The polymer/graphene based electrode shows better stability and flexibility, which introduces a promising future for highperformance flexible electronic/optoelectronic devices.23,24 Kim et al. fabricated the novel ternary graphene transistor and tailored the work function of CVD graphene by chemical doping with polyacrylic acid (PAA) and polyethylenimine (PEI).25

Nowadays, graphene electrodes are widely used in optoelectronic devices, however performance has been suffered due to its low work function. Therefore, doping is used as a simple and cost-effective approach to tune the work function of graphene.<sup>26</sup> The decoration of graphene surface with poly (3,4ethylenedioxythiophene): polystyrene sulfonate (PEDOT:PSS) film through  $\pi$ - $\pi$  interaction is another practical approach to enhance the electrical and optical properties of TCEs.27 Lin and coworkers demonstrated that the PEDOT:PSS has higher work function than the graphene and behave as p-type doped, thus the deposition of PEDOT:PSS film onto the graphene surface induces p-type doping and increases the electrical conductivity of the graphene.<sup>28</sup> Kim et al. developed a nanocomposite of PEDOT:PSS/graphene and improved electrical and thermoelectric performance of the nanocomposite film due to non-covalent nature of interaction between PEDOT:PSS film and graphene layer.29 Currently, most of the electronic/optoelectronic devices used PEDOT:PSS coating over the graphene electrodes not only for improvement of device performance but also maintained optical transparency. However, the electronic properties of CVD grown SLG by coating of thin transparent conductive films of PEDOT:PSS has not been much investigated so far.

In this work we have tuned the electronic properties of CVD grown SLG by deposition of thin transparent conducting polymer. The thin layers of different concentrations of PEDOT:PSS were uniformly deposited on CVD grown SLG by spin coating technique and utilized to modulate the electronic assets of graphene. The deposition of PEDOT:PSS on the CVD grown SLG was investigated carefully by electrical charge transport measurement, Raman spectroscopy and Kelvin probe force microscopy (KPFM) under ambient conditions. The Raman peak shifts were monitored after the deposition of PEDOT:PSS films on CVD graphene, which reveals p-type doping of graphene. The homogeneous deposition of PEDOT:PSS over the SLG was observed by atomic force microscopy (AFM) and scanning electron microscopy (SEM) techniques. The Dirac points shifted toward positive voltage with increasing concentration of PEDOT:PSS confirmed p-type doping of SLG. The change in carrier concentration and improvement in mobility confirmed the effect of PEDOT:PSS deposition on the SLG. Finally, the work function variation of SLG tested before and after the deposition of PEDOT:PSS film using the KPFM technique. As a result, the increased work function of doped SLG reveals  $E_{\rm F}$  shift towards valance band.

#### **Experimental section**

#### Synthesis of SLG by CVD method

A high-quality SLG film was grown on a single crystal copper (Cu) substrate using the CVD approach, as discussed previously in detail.<sup>15,30,31</sup> Briefly, the Cu foil (Alfa Aesar, Product code-13382) with the thickness of 25 µm was kept in a CVD chamber and annealed at 830 °C for 1 hour under the 40 sccm of hydrogen (H<sub>2</sub>) gas atmosphere at the pressure of  $\sim 10^{-4}$  mTorr. Then, the continuous flow of argon (Ar) and methane  $(CH_4)$ gases at the rate of 40 sccm and 1 sccm was introduced at the higher pressure of  $10^{-2}$  Torr for 3 min. Then, the samples were cooled down to RT in the H<sub>2</sub> gas atmosphere. To transfer SLG onto a SiO<sub>2</sub>/Si substrate using wet transfer technique, polymethyl methacrylate (PMMA) film was spin-coated on the top surface of the CVD grown graphene/Cu. Further, PMMA coated graphene/Cu film was dipped into commercial Cu etchant to etch the Cu foil. The CVD grown SLG film was rinsed with deionized water (DI) many times. Finally, SLG was transferred to a highly p-doped Si substrate with 300 nm SiO<sub>2</sub> dielectric with patterned Au electrodes. The PMMA film was removed from the graphene surface by acetone immersion for 1 hour, and then was rinsed in isopropyl alcohol. The source and drain (Au, 30 nm) metal electrodes were thermally evaporated at the two ends of G/SiO<sub>2</sub>/Si substrate using a shadow mask method. The device architecture of doped SLG is depicted in Fig. 1.

#### **PEDOT:PSS doping and characterization**

PEDOT:PSS solution (2.3 w/v in DI water) was obtained from Sigma Aldrich USA. Before doping, the PEDOT:PSS solution was diluted to two different concentrations, *i.e.*, 0.78 w/v and 1.04 w/



Fig. 1 Schematic diagram of PEDOT:PSS doped SLG field effect transistor.

v. The diluted solutions were spin-coated over the SLG coated SiO<sub>2</sub> substrates at 4000 rpm for 30 seconds. After spin-coating on graphene, the substrates were annealed at 100 °C for complete removal of residual water. To understand the doping effect of PEDOT:PSS on SLG, Raman spectroscopy measurements were conducted by Raman spectrometer (WiTec Alpha 300R, Germany) with 532 nm laser excitation and average power less than  $\sim$ 1 mW to avoiding heating effect. The charge transfer mechanism between SLG and PEDOT:PSS films were monitored by Raman spectra, and all the Raman peaks fitted with single Lorentzian function. The surface morphology of samples was observed by AFM (Asylum MFP-3D, UK) and SEM (GEMINI ZEISS, UK). We have also measured the thickness of 0.78 w/v PEDOT:PSS coated film by AFM. All the electrical measurements were examined using Keithley source measure unit model (2612A, USA) under ambient conditions. The electrical measurements were performed on different SLG devices before and after the doping of PEDOT:PSS. For the work function measurement, the surface potential of with and without doped samples were measured by KPFM (Asylum MFP-3D, UK).

#### **Results and discussion**

The Raman spectroscopy is a non-destructive and efficient technique to characterize the graphene structural and electronic properties. The Raman spectra of pristine graphene and different concentration PEDOT:PSS doped SLG are shown in Fig. 2a and b. The Raman spectra confirm the evidence of graphene with signature peaks D, G, and 2D. Notably, Raman peaks of pristine graphene are located at nearly 1339 cm<sup>-1</sup>, 1580 cm<sup>-1</sup>, and 2672 cm<sup>-1</sup>, respectively. The D peak generated due to breathing mode of sp<sup>2</sup> carbon atom ring and G peak is related to the C-C stretching of sp<sup>2</sup> carbon atoms.<sup>31</sup> The 2D peak is originates from the vibration of second order phonons near the K point, which is always present in SLG or few-layer graphene.32 Fig. 2b represents the Raman spectra comparing the G and 2D peak positions of PEDOT:PSS doped SLG with the pristine SLG. After analyzing the Raman spectra of various SLG devices from different positions, it is found that the G peaks upshifted by 4 cm<sup>-1</sup>, while a small upshift ( $\sim 1 \text{ cm}^{-1}$ ) is observed in the 2D peak position for 0.78 w/v PEDOT:PSS doped SLG. Although, comparing with pristine graphene the G and 2D peak positions of 1.04 w/v PEDOT:PSS doped SLG upshifted by 5 cm<sup>-1</sup> and 4 cm<sup>-1</sup>, respectively. Therefore, upshifting of G and 2D peaks in PEDOT:PSS doped SLG reveals p-type doping of graphene, which is consistent with previous report.<sup>33</sup> The position of the G peak shift in doped graphene related to change in sp<sup>2</sup> bond strength and phonon energy.<sup>34</sup> In p-type doping of graphene, electrons are removed from antibonding orbitals and thus expectation of G peak hardening. Also, the Fermi level of graphene shifted away from the Dirac point after doping and thus the electron-hole pair generation is reduced.<sup>34</sup> Therefore, recombination probability of excited charge carriers is reduced, which allows non-adiabatic elimination of Kohn anomaly from the  $\Gamma$  point and increased the phonon energy. The total response of the doping will be the combination of charge transfer and nondiabetic effects. Moreover, the intensity and



**Fig. 2** (a) Raman spectra of pristine and PEDOT:PSS doped SLG. (b) Shifting in G and 2D peaks of pristine and PEDOT:PSS doped SLG. (c) Variation of intensity ratio  $I_D/I_G$  and  $I_{2D}/I_G$  of pristine and PEDOT:PSS doped SLG as a function of doping concentrations of PEDOT:PSS (P stands for pristine SLG).

broadening of the 2D peaks are sensitive to crystal defects and carrier doping in graphene.<sup>35</sup> Fig. 2b shows that the 2D peak intensity of SLG decreases after the doping of 0.78 w/v and 1.04 w/v PEDOT:PSS doping due to charge scattering effect. However, relative shift of Raman peaks is induced by mainly two reasons either carrier doping or mechanical strain.<sup>36</sup> If the shift in G peak is more substantial than the 2D peak, it is caused by carrier doping in graphene. On the other hand, if the Raman peaks shift due to mechanical strain, the G peak would be less shifted than the 2D peak. In our case, G peak shift is more substantial

#### Paper

than the 2D peak shift for PEDOT:PSS doped SLG, which suggests Raman peak shift due to carrier doping.

The peak intensity ratio  $I_{2D}/I_{G}$  is another approach to understand the doping level in the graphene layer.32 Fig. 2c illustrates that the relative  $I_{2D}/I_{G}$  ratio of pristine graphene is more than two times ( $\sim$ 3.17) and the full-width half maximum (FWHM) of the 2D peak is  $\sim$ 34 cm<sup>-1</sup>, which revealed the pristine graphene used in our experimental work is SLG. The  $I_{2D}/I_{G}$ value decreased from 3.17 for pristine graphene to 1.19 for 0.78 w/v PEDOT:PSS doped SLG and further decreased to  $\sim$ 1.16 for 1.04 w/v PEDOT:PSS doped SLG. Change in  $I_{\rm 2D}/I_{\rm G}$  ratio indicates that the carrier concentration of CVD grown SLG increases after PEDOT:PSS doping, a similar result have been reported previously.37 As shown in Fig. 2c, we have plotted peak intensity ratio of D and G peaks  $(I_D/I_G)$  as function of concentration of PEDOT:PSS on graphene. After deposition of PEDOT:PSS films on graphene, initially the intensity of D peak increase sharply and then get saturated. This indicates that interaction of PEDOT:PSS molecules with graphene and created some disorders on graphene surface.

Morphological characterization of pristine SLG and PEDOT:PSS doped SLG was imaged by AFM with tapping mode as shown in Fig. 3a–c. It can be seen that the surface morphology of pristine SLG changes after PEDOT:PSS doping.

The root mean square ( $R_Z$ ) roughness parameter for SLG and 0.78 w/v PEDOT:PSS doped SLG are estimated to be 1.63 nm and 4.22 nm, respectively. Further, for increased concentration (1.04 w/v) of PEDOT:PSS, the  $R_Z$  for SLG significantly decreased from 4.22 nm to 3.10 nm. The much smaller  $R_Z$  for PEDOT:PSS doped SLG indicates that the PEDOT:PSS film is well dispersed on the graphene surface. We have also measured the thickness of 0.78 w/v PEDOT:PSS coated film by AFM and thickness is found to be 55 nm (ESI Fig. S1†). The measured surface roughness of PEDOT:PSS doped CVD grown SLG is less than a metal oxide doped graphene-based transparent electrode.<sup>38</sup> Further, the morphology of PEDOT:PSS film on the SLG surface was characterized by SEM and SEM image of 1.04 w/v PEDOT:PSS films are uniformly deposited onto whole area of CVD grown SLG.

To investigate the effect of PEDOT:PSS doping on the electronic properties of SLG, the electrical transport measurement was performed for back-gated SLG device before and after PEDOT:PSS doping under ambient condition. The measurement setup of fabricated device is shown in Fig. 1, where drainsource voltage ( $V_{DS}$ ) is biased at 1.0 V, while source electrode is fixed at 0 V. In our back-gated SLG device, highly p-doped Si substrate acts as gate electrode. During the measurement, the drain and gate electrodes were biased at variable voltages.



Fig. 3 AFM height image of (a) pristine, (b) 0.78 w/v PEDOT:PSS doped and (c) 1.04 w/v PEDOT:PSS doped SLG on SiO<sub>2</sub> substrate. (d) SEM image of 1.04 w/v PEDOT:PSS doped SLG.



Fig. 4 Transfer characteristics curve of (a) pristine SLG. (b) 0.78 w/v PEDOT:PSS doped SLG. (c) 1.04 w/v PEDOT:PSS doped SLG. (d) Variation of Dirac point as a function of PEDOT:PSS doping concentrations on SLG (P stands for pristine SLG).

Fig. 4a–c shows the  $I_{DS}$ – $V_G$  characteristic curve for pristine and different concentrations of PEDOT:PSS deposited SLG with the gate voltage ( $V_{\rm G}$ ) sweeping from -45 V to 45 V. The minimum conductivity point indicates the charge neutralization point, which corresponds to the Dirac point of the SLG fabricated devices. The Dirac point of pristine SLG positioned at 4.50  $\pm$ 0.45 V (Fig. 4a), imposes p-type doping may be due to unavoidable doping from ambient oxygen molecules and the underlying SiO<sub>2</sub> layer.<sup>39</sup> After the doping, the Dirac point shifted to  ${\sim}23$   $\pm$  1.20 V and  ${\sim}27$   $\pm$  0.91 V for 0.78 w/v and 1.04 w/v PEDOT:PSS doped SLG, respectively as depicted in Fig. 4b and c, this result is consistent with other polymer doped SLG device.<sup>25</sup> The repeatability of our study is further demonstrated by the measurements of different SLG based fabricated devices. The variation of Dirac point as a function of PEDOT:PSS doping concentration is shown in Fig. 4d. The mechanism of electrons transfer from SLG to PEDOT:PSS film is also understood by the work functions differences between these two, which imposes p-type doping for graphene.40

The effect of PEDOT:PSS doping on the carrier concentration of SLG can be calculated from the Dirac point shift in  $I_{\text{DS}}-V_{\text{G}}$ characteristic using the formula  $n = C_{\text{g}}(V_{\text{Dirac}})/e$ ,<sup>8</sup> where  $C_{\text{g}}$  is the gate oxide capacitance of ~11.5 nF cm<sup>-2</sup> for 300 nm thick SiO<sub>2</sub> substrate, *e* is the electronic charge, and  $V_{\text{Dirac}}$  is the Dirac point of respective sample. The hole carrier concentration of pristine graphene is estimated to be  $3.24 \times 10^{11}$  cm<sup>-2</sup>, similar value has been reported.<sup>38</sup> Fig. 5a illustrates the concentration of pristine and 0.78 w/v to 1.04 w/v PEDOT:PSS doped graphene. The value of hole carrier concentration of 0.78 w/v and 1.04 w/v PEDOT:PSS doped graphene can be estimated as  $1.68 \times 10^{12}$ cm<sup>-2</sup> and  $1.93 \times 10^{12}$  cm<sup>-2</sup>, respectively. Therefore, the increases in hole carrier concentration of SLG demonstrates that the PEDOT:PSS allow to modulates the doping level of CVD grown SLG. To further demonstrate the charge transport, the hole and electron mobility of SLG with and without PEDOT:PSS

doping can be obtained by $\mu = \left(\frac{1}{C_g}\right) \left(\frac{\partial \sigma}{\partial V_{GS}}\right)$ ,<sup>8</sup> where *s* is the conductivity of the samples, and  $V_{GS}$  is biased gate voltage. The hole and electron mobility of with and without doped SLG samples were extracted by using the linear slope region of their respective conductivity curves. As a result, the carrier mobility of the SLG increases with increasing doping concentration of PEDOT:PSS as depicted in Fig. 5b, similar improvement in carrier mobility has been reported for other systems.<sup>41</sup> Meanwhile, CVD grown SLG on SiO<sub>2</sub> substrates exhibits low carrier mobility, which may be due to extrinsic charge impurity scattering or phonon scattering of substrate.<sup>39,42</sup> Fig. 5b illustrates that the hole mobility is more than two times of electron mobility due to unequal scattering of holes and electrons by the impurity charges. The asymmetry in carrier mobility of SLG



Fig. 5 (a) Charge carrier density of pristine and PEDOT:PSS doped SLG. (b) Variation of charge carrier (holes and electrons) mobility as a function of doping concentrations of PEDOT:PSS (P stands for pristine SLG).

gradually decreases with increasing concentration of PEDOT:PSS may be due to screening of scattering effects.<sup>42</sup> In our case, it may be possible that the PEDOT:PSS doping on graphene surface created a dipole field due to polar PEDOT:PSS molecules.<sup>43</sup> Moreover, the dipole field leads to enhance and balance the carrier mobility of graphene by neutralizing the charge impurity scattering effect.<sup>39</sup> The similar phenomenon

have been observed for other polymer coated graphene system.<sup>23</sup>

In KPFM, the electrostatic surface potential can be measured by the conducting cantilever tip vibration along the perpendicular to the plane of sample. The measured electrostatic surface potential represents the contact potential difference (CPD) between cantilever tip and sample. The detail mechanism



Fig. 6 KPFM Images of (a) pristine SLG (b) 0.78 w/v PEDOT:PSS doped SLG (c) 1.04 w/v PEDOT:PSS doped SLG (d) schematic representation of energy band diagram of different samples (P stands for pristine SLG).

of KPFM for work function (WF) measurement has been discussed in literatures.<sup>44,45</sup> We have also discussed the principle of KPFM technique in our ESI.<sup>†</sup> The WF modulation of pristine SLG after the deposition of PEDOT:PSS as illustrated in Fig. 6a-c. The KPFM and AFM images have been scanned at the same locations. The KPFM images were recorded in constant height (50 nm) mode *via* Ti/Ir (5/20) coated Si cantilever tip at applied voltage ~1 V and resonance frequency ~70 kHz. The following equation can be used for the measurement of WF of pristine graphene and doped samples.<sup>44</sup>

$$\Delta V_{
m CPD} = V_{
m g} - V_{
m tip} = rac{arphi_{
m tip} - arphi_{
m sample}}{e}$$

Here,  $V_{\rm g}$  and  $V_{\rm tip}$  are the average surface potential of graphene and tip, respectively. Also,  $\varphi_{\rm tip}$  and  $\varphi_{\rm sample}$  are the WF of the tip and sample, respectively, and e is the electronic charge. The WF of Ti/Ir coated Si tip ( $\varphi_{tip}$ ) is 5.0 eV. Thus, the WF of the samples can be extracted by  $\varphi_{\text{sample}} = \varphi_{\text{tip}} - e\Delta V_{\text{CPD}}$ . It is reported that the WF of graphene can be modulated by shifting the  $E_{\rm F}$  due to the addition of n-type or p-type dopant.<sup>46</sup> Therefore, the dopants with higher (lower) WF than pristine graphene are used to increased (decreased) the WF of graphene. Also, the WF of graphene depends on the concentration of dopants. As reported in the literature, the PEDOT:PSS exhibits more WF than graphene and act as a p-type dopant for graphene.<sup>28</sup> Therefore, the WF of pristine SLG can be increased after PEDOT:PSS doping. Utilizing the WF of tip, the average CPD of ~138 mV was observed for pristine SLG, whereas the average CPD value for 0.75 w/v and 1.04 w/v PEDOT:PSS doped SLG are evaluated as -59 mV and -78 mV. Thus, the decrease of CPD value  $\sim 197$  mV and  ${\sim}216$  mV, respectively for 0.75 w/v and 1.04 w/v PEDOT:PSS doped SLG could be exhibited in the shift of  $E_{\rm F}$  of PEDOT:PSS doped SLG. The calculated WF of pristine SLG is 4.86 eV, which is slightly higher than the previously reported value, reveals ptype doping possibly due to unintentional doping from ambient oxygen molecules.15 The WF is attributed to the energy difference between vacuum level  $(E_{\rm vac})$  and  $E_{\rm F}$ , which is mentioned in the energy level diagram (Fig. 6d). When the doping concentration of PEDOT:PSS on SLG increases, the energy gap between  $E_{\rm vac}$  and  $E_{\rm F}$  is broadened because the  $E_{\rm F}$ shifted towards the valance band relative to Dirac point. Thus, the WF evaluated for 0.78 w/v and 1.04 w/v PEDOT:PSS doped SLG is found to be 5.06 eV and 5.08 eV, respectively and similar results have been reported for other system.25 The WF of PEDOT:PSS coated CVD grown SLG is close to the WF of gold  $(\sim 5.1 \text{ eV})$ . Therefore, our PEDOT:PSS coated CVD grown SLG can be used instead of Au electrode in electronic/optoelectronic devices. The PEDOT:PSS coated CVD grown SLG electrode may be cost effective and flexible than Au electrode.

### Conclusion

Here, we have investigated the effect of different concentrations PEDOT:PSS doping on the electronic properties of CVD grown SLG. The electrical transport and Raman spectroscopy measurements revealed that the PEDOT:PSS coating imposes pdoping on CVD grown SLG. The shift of Dirac points, improvement in mobility and change in carrier concentration are investigated as a function of concentrations of PEDOT:PSS doping on CVD grown graphene. We have also measured the work function of pristine and PEDOT:PSS coated CVD grown SLG by using KPFM and observed that PEDOT:PSS doping significantly modulates the work function of graphene. Our studies will provide better understanding to utilizing CVD grown graphene film coated with PEDOT:PSS as TCEs in future flexible electronic/optoelectronic devices applications.

### Conflict of interest

There is no conflict of interest.

## Acknowledgements

All the authors and Dr A. K. Singh greatly acknowledges to Prof. Jonghwa Eom, Sejong University, South Korea, for providing the CVD graphene. We are also acknowledged to DST (Project IFA-13 PH-53), India, and TEQIP-III for their supports. Micro-Raman spectroscopy measurement, AFM and KPFM were supported by the Center of Nanoscience and Material Science Engineering Department, IIT Kanpur, India, respectively. Authors are also thankful to CIF, IIT (BHU), Varanasi, India, for providing characterizations facilities of samples.

#### References

- 1 H. Yooji, C. Junhee, K. Ji-Weon, L. Jin-Woo, J. G. Kim, H. Hwang, K. W. Choi, W. Lee and J. B. Kwon, *Sci. Rep.*, 2020, **10**, 1–8.
- 2 G. Xu, P. Han, X. Wang, X. Zhou, X. Han, D. Lu, H. Liu, J. Zhao, J. Ma and G. Cui, *ACS Appl. Mater. Interfaces*, 2020, 12, 9468–9477.
- 3 A. K. Singh and J. Eom, ACS Appl. Mater. Interfaces, 2014, 6, 2493–2496.
- 4 J. Ma, M. Zhang, L. Dong, Y. Sun, Y. Su, Z. Xue and Z. Di, *AIP Adv.*, 2019, **9**, 075207.
- 5 A. K. Singh, C. Hwang and J. Eom, *ACS Appl. Mater. Interfaces*, 2016, **8**, 34699–34705.
- 6 A. M. Bazargan, F. Sharif, S. Mazinani and N. Naderi, J. Mater. Sci., 2017, 28, 2962–2969.
- 7 P. Kumar, A. K. Singh, S. Hussain, K. N. Hui, K. San Hui, J. Eom, J. Jung and J. Singh, *Reviews in Advanced Sciences* and Engineering, 2013, 2(4), 238–258.
- 8 K. S. Novoselov, A. K. Geim, S. V. Morozov, D. Jiang, Y. Zhang, S. V. Dubonos, I. V. Grigorieva and A. A. Firsov, *Science*, 2004, **306**, 666–669.
- 9 F. Schwierz, Nature, 2011, 41, 472.
- 10 R. R. Nair, P. Blake, A. N. Grigorenko, K. S. Novoselov, T. J. Booth, T. Stauber, N. M. R. Peres and A. K. Geim, *Science*, 2008, **320**, 1308.
- 11 F. Qing, Y. Hou, R. Stehle and X. Li, *APL Mater.*, 2019, 7, 020903.
- 12 Z. Cai, B. Liu, X. Zou and H. M. Cheng, *Chem. Rev.*, 2018, **118**, 6091–6133.

- 13 M. S. Chae, T. H. Lee, K. R. Son, Y. W. Kim, K. S. Hwang and T. G. Kim, *Nanoscale Horiz.*, 2019, 4, 610–618.
- 14 A. K. Singh, V. Chaudhary, A. K. Singh and S. R. P. Sinha, *Synth. Met.*, 2020, **264**, 116389.
- 15 M. H. Kang, G. Qiu, B. Chen, A. Jouvray, K. B. Teo, C. Cepek, L. Wu, J. Kim, W. I. Milne and M. T. Cole, *J. Mater. Chem. C*, 2017, 5, 9886–9897.
- 16 A. K. Singh, M. W. Iqbal, V. K. Singh, M. Z. Iqbal, J. H. Lee, S. H. Chun, K. Shin and J. Eom, *J. Mater. Chem.*, 2012, 22, 15168–15174.
- 17 T. H. Han, S. J. Kwon, N. Li, H. K. Seo, W. Xu, K. S. Kim and T. W. Lee, *Angew. Chem.*, 2016, **128**, 6305–6309.
- 18 T. Cui, R. Lv, Z. H. Huang, S. Chen, Z. Zhang, X. Gan, Y. Jia, X. Li, K. Wang, D. Wu and F. Kang, *J. Mater. Chem. A*, 2013, 1, 5736–5740.
- 19 A. K. Singh, V. Chaudhary, A. K. Singh and S. R. P. Sinha, Synth. Met., 2019, 256, 116155.
- 20 T. H. Han, Y. Lee, M. R. Choi, S. H. Woo, S. H. Bae,
  B. H. Hong, J. H. Ahn and T. W. Lee, *Nat. Photonics*, 2012,
  6, 105–110.
- 21 P. You, Z. Liu, Q. Tai, S. Liu and F. Yan, *Adv. Mater.*, 2015, 27, 3632–3638.
- 22 D. A. Mengistie, M. A. Ibrahem, P. C. Wang and C. W. Chu, *ACS Appl. Mater. Interfaces*, 2014, **6**, 2292–2299.
- 23 J. M. Yun, S. Park, Y. H. Hwang, E. S. Lee, U. Maiti, H. Moon,
  B. H. Kim, B. S. Bae, Y. H. Kim and S. O. Kim, *ACS Nano*, 2014, 8, 650–656.
- 24 C. Biswas, I. Candan, Y. Alaskar, H. Qasem, W. Zhang,
  A. Z. Stieg, Y. H. Xie and K. L. Wang, *Sci. Rep.*, 2018, 8(1), 1–12.
- 25 S. Y. Kim, M. B. Kim, H. J. Hwang, B. Allouche and B. H. Lee, *Jpn. J. Appl. Phys.*, 2019, **58**, SBBH04.
- 26 B. V. R. S. Subramanyam, P. C. Mahakul, K. Sa, J. Raiguru, I. Alam, S. Das, M. Mondal, S. Subudhi and P. Mahanandia, *Sol. Energy*, 2019, **186**, 146–155.
- 27 X. Z. Zhu, Y. Y. Han, Y. Liu, K. Q. Ruan, M. F. Xu, Z. K. Wang, J. S. Jie and L. S. Liao, *Organic Electronics*, 2013, 14, 3348– 3354.

- 28 P. Lin, F. Yan, J. Yu, H. L. Chan and M. Yang, *Adv. Mater.*, 2010, 22, 3655–3660.
- 29 G. H. Kim, D. H. Hwang and S. I. Woo, *Phys. Chem. Chem. Phys.*, 2012, **14**, 3530–3536.
- 30 Y. Yao and C. P. Wong, Carbon, 2012, 50, 5203-5209.
- 31 Y. Yao, Z. Li, Z. Lin, K. S. Moon, J. Agar and C. Wong, *J. Phys. Chem. C*, 2011, **115**, 5232–5238.
- 32 A. C. Ferrari, J. C. Meyer, V. Scardaci, C. Casiraghi, M. Lazzeri, F. Mauri, S. Piscanec, D. Jiang, K. S. Novoselov, S. Roth and A. K. Geim, *Phys. Rev. Lett.*, 2006, **97**, 187401.
- 33 J. B. Lee, K. Rana, B. H. Seo, J. Y. Oh, U. Jeong and J. H. Ahn, *Carbon*, 2015, **85**, 261–268.
- 34 M. Lazzeri and F. Mauri, *Phys. Rev. Lett.*, 2006, **97**(26), 266407.
- 35 P. Venezuela, M. Lazzeri and F. Mauri, *Phys. Rev. B: Condens. Matter Mater. Phys.*, 2011, **84**, 035433.
- 36 J. E. Lee, G. Ahn, J. Shim, Y. S. Lee and S. Ryu, *Nat. Commun.*, 2012, 3, 1–8.
- 37 J. K. Chang, C. C. Hsu, S. Y. Liu, C. I. Wu, M. Gharib and N. C. Yeh, *J. Appl. Phys.*, 2016, **119**, 235301.
- 38 T. L. Phan, M. Kang, S. H. Choi, Y. J. Kim, H. Jung and I. T. Yoon, *Appl. Phys. Lett.*, 2017, **111**, 153103.
- 39 J. Chen, C. Jang, S. Xiao and M. Ishigami, *Nat. Nanotechnol.*, 2008, **3**, 206–209.
- 40 B. H. Lee, J. H. Lee, Y. H. Kahan, N. Kim, Y. J. Kim, J. Lee, T. Lee and K. Lee, *Adv. Funct. Mater.*, 2014, 24, 1847–1856.
- 41 M. J. Deka and D. Chowdhury, J. Phys. Chem. C, 2016, 120, 4121-4129.
- 42 F. Chen, J. Xia and N. Tao, Nano Lett., 2009, 9, 1621-1625.
- 43 J. Zhang and J. Liu, Semiconductors, 2017, 51, 1611-1614.
- 44 E. G. Castanon, A. F. Scarioni, H. W. Schumacher, S. Spencer, R. Perry, J. A. Vicary, C. A. Calliford and H. C. León, *J. Phys. Commun.*, 2020, 4, 095025.
- 45 M. Nonnenmacher, M. P. O'Boyle and H. K. Wickramasinghe, *Appl. Phys. Lett.*, 1991, **58**, 2921–2923.
- 46 S. A. Paniagua, J. Baltazar, H. Sojoudi, S. K. Mohapatra, S. Zhang, C. L. Henderson, S. Graham, S. Barlow and S. R. Marder, *Mater. Horiz.*, 2014, 1, 111–115.